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Re:	U.S. Serial No: 10/709,239 Group Art Unit: 2818 Confirmation No: 3238 Docket No: FIS920030375US1 (17192)	CC:	

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Applicant(s): Hui long Zhu, et al.

Docket No.

FIS920030375US1 (17192)

Application No.
10/709,239Filing Date
April 23, 2004Examiner
Calvin LeeGroup Art Unit
2818

Invention: STRUCTURES AND METHODS FOR MANUFACTURING OF DISLOCATION FREE STRESSED CHANNELS IN BULK SILICON AND SOI CMOS DEVICES BY GATE STRESS ENGINEERING WITH SiGe AND/OR Si:C

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TRANSMITTAL LETTER
(General - Patent Pending)Docket No.
FIS920030375US1 (17192)

In Re Application Of: Huilong Zhu, et al.

Application No.	Filing Date	Examiner	Customer No.	Group Art Unit	Confirmation No.
10/709,239	April 23, 2004	Calvin Lee	23389	2818	3238

Title: **STRUCTURES AND METHODS FOR MANUFACTURING OF DISLOCATION FREE STRESSED CHANNELS IN BULK SILICON AND SOI CMOS DEVICES BY GATE STRESS ENGINEERING WITH SiGe AND/OR Si:C**

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Dated: November 21, 2005

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TRANSMITTAL LETTER
(General - Patent Pending)Docket No.
FIS920030375US1 (17192)

In Re Application Of: Huilong Zhu, et al.

Application No. 10/709,239	Filing Date April 23, 2004	Examiner Calvin Lee	Customer No. 23389	Group Art Unit 2818	Confirmation No. 3238
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Title: **STRUCTURES AND METHODS FOR MANUFACTURING OF DISLOCATION FREE STRESSED CHANNELS IN BULK SILICON AND SOI CMOS DEVICES BY GATE STRESS ENGINEERING WITH SiGe AND/OR Si:C**

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Huilong Zhu, et al.

Examiner: Calvin Lee

Serial No: 10/709,239

Art Unit: 2818

Filed: April 23, 2004

Docket: FIS920030375US1 (17192)

For: STRUCTURES AND METHODS FOR
MANUFACTURING OF DISLOCATION
FREE STRESSED CHANNELS IN BULK
SILICON AND SOI CMOS DEVICES BY
GATE STRESS ENGINEERING WITH
SiGe AND/OR Si:C

Dated: November 21, 2005

Confirmation No: 3238

Commissioner of Patents and Trademarks
P.O. Box 1450
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RESPONSE UNDER 37 C.F.R. §§1.111 AND 1.143

Sir:

In response to the Office Action dated October 20, 2005, applicants provisionally elect, without traverse, the subject matter of Group II, i.e., Claims 1-13, for continued prosecution in the above-identified patent application.

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